EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	1970	438/3.ccls.	US-PGPUB; USPAT	OR	OFF	2006/05/27 16:33
L3	1821	257/295.ccls.	US-PGPUB; USPAT	OR	OFF	2006/05/27 16:52
L4	247	memory same (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene ferroelectric fluorine) same ((interface near (material layer film)) rutile (titanium adj (oxide dioxide)) "tio.sub.2") same (electrode aluminum titanium)	US-PGPUB; USPAT	OR	ON	2006/05/27 20:50
L5	149	memory and (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene ferroelectric fluorine) and ((interface near (material layer film)) rutile (titanium adj (oxide dioxide)) "tio.sub.2") and (electrode aluminum titanium)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/27 20:17
L6	4379	257/295.ccls. 257/310.ccls. 257/534.ccls. 257/535.ccls. 438/3. ccls.	US-PGPUB; USPAT	OR	OFF	2006/05/27 20:23
L7	1033	(memory cell) same (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene ferroelectric fluorine) same ((interface near (material layer film)) rutile (titanium adj (oxide dioxide)) "tio. sub.2") same (electrode aluminum titanium)	US-PGPUB; USPAT	OR	ON	2006/05/27 20:23
L8	122	L6 and L7	US-PGPUB; USPAT	OR	ON	2006/05/27 20:23
L9	1349	(memory cell) same (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene ferroelectric fluorine) same ((interface near (material layer film)) rutile (titanium adj (oxide dioxide)) "tio. sub.2")	US-PGPUB; USPAT	OR	ON	2006/05/27 20:32
L10	157	L6 and L9	US-PGPUB; USPAT	OR	ON	2006/05/27 20:32

EAST Search History

	.			,		
L11	7	(fram mram ferroelectric magnetoresistive feram) and (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene) and ((interface near (material layer film)) rutile (titanium adj (oxide dioxide)) "tio. sub.2")	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/27 20:39
L12	115	(fram mram ferroelectric magnetoresistive feram) same (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene) same ((interface near (material layer film)) rutile (titanium adj (oxide dioxide)) "tio. sub.2")	US-PGPUB; USPAT	OR	ON	2006/05/27 20:40
L13	3199	(fram mram ferroelectric magnetoresistive feram) same (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene)	US-PGPUB; USPAT	OR	ON	2006/05/27 20:45
L14	159	L6 and L13	US-PGPUB; USPAT	OR	ON	2006/05/27 20:45
L15	282	(memory and (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene ferroelectric fluorine) and ((interface near (material layer film)) rutile (titanium adj (oxide dioxide nitride)) "tio.sub.2" tin) and (electrode aluminum titanium)).clm.	US-PGPUB	OR	ON	2006/05/27 20:54
L16	126	(memory and (polymer polymeric copolymer vdf (vinyledene adj fluoride) tfe trifluoroethylene ferroelectric fluorine) and ((interface near (material layer film)) rutile (titanium adj (oxide dioxide nitride)) "tio.sub.2" tin) and (electrode aluminum titanium) and (rough roughness peak protuberance thick thickness greater)).clm.	US-PGPUB	OR	ON	2006/05/27 20:56